

Small Annealing System (for 1/4 piece of 2 inch)



Heating part

Reactor: Quartz tube ($\phi 50\text{mm}$)

Maximum heating temperature: 1100°C (Control thermocouple value)

Substrate size: 1/4 piece of 2 inch $\times 1\text{pc}$

Gas inlet: 1/4 SW

Transfer chamber

Transport mechanism: Transfer rod $\times 1\text{ST}$

Access door: ICF114 size $\times 1\text{ST}$

Vacuum exhaust

Rotary pump $\times 1\text{ST}$

Introduced gas

N₂ etc.

※Rapid thermal possible